

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Hui-Lin Chang et al.

Serial No.: 10/666,354

Filed: September 19, 2003

For: Two Step Post-Deposition Treatment of  
ILD Layer for a Layer Dielectric Constant  
and Improved Mechanical Properties

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Attorney Docket No.:  
TS02-1079/24061.500

Group Art Unit: 1765

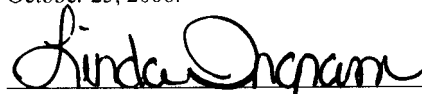
Examiner: Angadi, Maki A.

Conf. No. 8188

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Certificate of Service

I hereby certify that this correspondence is being filed with  
the U.S. Patent and Trademark Office via EFS-Web on  
October 25, 2006.

  
Linda Ingram

RESPONSE TO OFFICE ACTION

Sir:

No fees, including extension of time fees, are believed necessary for consideration of the present paper. However, if any fees, including extension of time fees, are necessary, the extension of time is hereby requested, and the Commissioner is hereby authorized to charge any fees, including those for the extension of time, to Haynes and Boone, LLP's Deposit Account No. 08-1394.

In response to the Office Action of August 4, 2006, please amend the above-identified application as follows:

**Listing of claims** begins on **page 2** of this paper.

**Remarks** begin on **page 8** of this paper.